

AMENDMENT TO THE SPECIFICATION

Please replace paragraph [0043] with the following amended paragraphs:

[0043] The light-diffusion layer 59 is formed through the diffusion process by adding a diffusion enhancer such as SiO₂ particles, beads or other projections to a lower surface of the third passivation layer 58. The lower surface of the light-diffusion layer 59 thus has a surface that includes a plurality of projections. The projections are formed in round shapes having smooth curves that extend towards and at least some of which contact the backlight unit 45. These round shapes may be substantially formed from a segment of a sphere (e.g. hemispherical), although they may be ellipsoidal, parabolic, or quonset-shaped for example. The light-diffusion layer 59 may be formed by performing an Anti-Glare process on the third passivation layer 58. The projections may be formed directly on the third passivation layer 58 or on a relatively thin layer 60 (thin compared with the third passivation layer 58) that is separate from the third passivation layer 58. This relatively thin layer may be used to provide additional benefits to the structure without increasing the thickness by a substantial amount. The density of these projections is substantially less than that of the beads in the third adhesive layer 56 of the related art and thus has the commensurate advantages described herein. The amount of Haze produced by the light-diffusion layer 59 and that produced by an adhesive layer having beads may be the same even though the density of the projections is substantially less than the density of beads added to the adhesive layer. The light-diffusion layer 59 may also be coated with an anti-reflection coating to reduce the amount of light reflected by the projections.